

REMARKS

Claims 1-8, 10-19 and 27-34 are pending in the present application. Claims 9 and 20-26 are cancelled herein. Claims 27-34 have been added, and claims 1, 11 and 19 have been amended. No new matter has been added.

Applicant wishes to thank the Examiner for indicating the allowable subject matter of claims 9-10 and 18-19. In view of this indication, limitations have been added to claims 1 and 11.

Independent claims 1 and 11 were both rejected under 35 U.S.C. §102(e) as being anticipated by Hwang (U.S. Patent No. 6,492,198, hereinafter "Hwang"). Each of the dependent claims, other than those noted above, were rejected under either 35 U.S.C. § 102(e) or 35 U.S.C. § 103 over Hwang, either alone or in combination with other references. Applicant respectfully traverses these rejections.

Claim 1 has been amended to include the limitations of claim 9, which the Examiner indicated was allowable. In particular, claim 1 now recites that "the wafer is etched prior to the coating with the organic protective layer." As noted in the Office Action, this claim is allowable.

Similarly, claim 11 has been amended to recite that "the semiconductor device is etched prior to the coating with the organic protective layer." It is respectfully submitted that this claim is also allowable.

Claim 10, which the Examiner has indicated is allowable, has been rewritten in independent form.

Claims 27-34 have been added herein. No new matter has been added. It is respectfully submitted that the references of record do not teach or suggest the limitations of claim 27. Allowance of these claims is therefore respectfully requested.

In view of the above, Applicants respectfully submit that the application is in condition for allowance and request that the Examiner pass the case to issuance. If the Examiner should have any questions, Applicants request that the Examiner contact Applicants' attorney at the address below. No fee is believed due in connection with this filing. However, in the event that there are any fees due, please charge the same, or credit any overpayment, to Deposit Account No. 50-1065.

Respectfully submitted,



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Date

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